# Signals in particle detectors

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**Lecture 5:** Possible overflow, wrap-up and Q&A session
Extensions of the Ramo-Shockley theorem

In the first two lectures we assumed that

- the electrodes are perfectly conducting electrodes
- the electrodes are grounded (measuring induced current) or insulated (measuring induced voltage)
- the detector materials are perfect insulators

In a realistic detector, the electrodes are however neither grounded nor insulated, but they are connected to ground and among each other by impedance elements e.g. amplifiers, load resistors etc.

In addition the detector materials can have finite conductivity, like it is the case in Resistive Plate Chambers (RPCs), un-depleted silicon sensors, and detectors with resistive layers for application of High Voltage, spreading of charge or discharge protection.

For these situations we have to extend the Ramo-Schockley theorem.
Electrostatic in dielectric media

\[ \nabla [\varepsilon(x) \nabla \varphi(x)] = -\rho(x) \quad \varphi(x)|_{x=A_n} = V_n \]

A solution that satisfies the boundary conditions (and is therefore unique):

\[ \nabla [\varepsilon(x) \nabla \varphi_n(x)] = -\rho_0(x) \quad \varphi(x)|_{x=A_n} = 0 \]

\[ \nabla [\varepsilon(x) \nabla \psi_n(x)] = 0 \quad \psi_n(x)|_{x=A_n} = V_w \delta_{mn} \]

\[ \varphi(x) = \varphi_0(x) + \sum_{n=0}^{N} \frac{V_n}{V_w} \psi_n(x) \]

\[ Q_n = \int_{A_n} \varepsilon(x) \mathbf{E}(x) \, dA \]

\[ c_{mn} = \frac{1}{V_w} \int_{A_n} \varepsilon(x) \nabla \psi_m(x) \, dA \]

Ramo-Shockley theorem holds also for dielectric media!
Conductivity, volume resistivity

Volume resistivity $\rho$ [Ωm] – typically expressed as Ωcm
Conductivity $\sigma = 1/\rho$ [Siemens]

Surface resistivity $R$ [Ω/square]

Nonuniform conductivity (volume resistivity) relates the local current density to the local electric field:

$$j(x) = \sigma(x) E(x) = -\sigma(x) \nabla \varphi(x)$$

$$R_1 = \rho \frac{L}{A} \quad I = \frac{U}{R_1}$$

$$R_1 = R \frac{a}{b}$$
In a medium with conductivity \( \sigma \), there will be a current flowing according to

\[
\mathbf{j}(\mathbf{x}, t) = \sigma(\mathbf{x})\mathbf{E}(\mathbf{x}, t) = -\sigma(\mathbf{x})\nabla \varphi(\mathbf{x})
\]

In addition to this current, we can have an externally impressed current \( \mathbf{j}_e(\mathbf{x}, t) \), so the total current is

\[
\mathbf{j}(\mathbf{x}, t) = \sigma(\mathbf{x})\mathbf{E}(\mathbf{x}, t) + \mathbf{j}_e(\mathbf{x}, t) = -\sigma(\mathbf{x})\nabla \varphi(\mathbf{x}, t) + \mathbf{j}_e(\mathbf{x}, t)
\]

Assuming the variation of the electric field to be slow, we can use the Poisson equation for a medium given by

\[
\nabla[\varepsilon(\mathbf{x})\nabla \varphi(\mathbf{x}, t)] = -\rho(\mathbf{x}, t)
\]

Performing the time derivative, we have

\[
\nabla[\varepsilon(\mathbf{x})\nabla \frac{\partial \varphi(\mathbf{x}, t)}{\partial t}] = -\frac{\partial \rho(\mathbf{x}, t)}{\partial t}
\]

And using

\[
\nabla \mathbf{j}(\mathbf{x}, t) = -\frac{\partial \rho(\mathbf{x}, t)}{\partial t}
\]

we have

\[
\nabla \left[ \varepsilon(\mathbf{x})\nabla \frac{\partial \varphi(\mathbf{x}, t)}{\partial t} + \sigma(\mathbf{x})\nabla \varphi(\mathbf{x}, t) \right] = -\frac{\partial \rho_e(\mathbf{x}, t)}{\partial t}
\]

Where \( \rho_e \) is the ‘externally impressed’ charge density.
Quasi-static Approximation of Maxwell’s equations

Assuming a conductivity \( \sigma \) of the material we have a current according to

\[
j(x, t) = \sigma(x) E(x, t)
\]

Maxwell’s equations for this situation

\[
\begin{align*}
\nabla D(x, t) &= \rho(x, t) \\
\nabla B(x, t) &= 0 \\
\nabla \times E(x, t) &= -\frac{\partial B(x, t)}{\partial t} \\
\nabla \times H(x, t) &= \frac{\partial D(x, t)}{\partial t} + j_e(x, t) + \sigma(x) E(x, t)
\end{align*}
\]

The current \( j_e(x, t) \) is an 'externally impressed' current, which is related to the 'externally impressed' charge density \( \rho_e \) by

\[
\nabla j_e(x, t) = -\frac{\partial \rho_e(x, t)}{\partial t}
\]

If we assume that this impressed current is only changing slowly we can neglect Faraday’s law and approximate

\[
\nabla \times E(x, t) \approx 0 \quad \Rightarrow \quad E(x, t) = -\nabla \varphi(x, t)
\]

and we can then write the electric field as the gradient of a potential, \( \nabla \varphi(x, t) \) by taking the divergence of the last equation …
Laplace Transform, Fourier Transform

Bilateral Laplace Transform

\[ \mathcal{L}[f(t)] = F(s) = \int_{-\infty}^{\infty} f(t) e^{-st} \, dt, \]

Fourier Transform

\[ \mathcal{F}[f(t)] = \int_{-\infty}^{\infty} f(t) e^{-i\omega t} \, dt = F(i\omega) \quad \omega = 2\pi f, \]

Inverse Laplace and Fourier Transforms

\[ f(t) = \frac{1}{2\pi i} \int_{c-i\infty}^{c+i\infty} F(s) e^{st} \, ds \quad f(t) = \frac{1}{2\pi} \int_{-\infty}^{\infty} F(i\omega) e^{i\omega t} \, d\omega. \]

Relations that hold for Laplace and Fourier Transforms

(a) Addition
\[ \mathcal{L}[af(t) + bg(t)] = aF(s) + bG(s) \]

(b) Convolution
\[ \mathcal{L}\left[ \int_{-\infty}^{\infty} f(t - t')g(t') \, dt' \right] = F(s)G(s) \]

(c) Time differentiation
\[ \mathcal{L}[f^{(n)}(t)] = s^n F(s) \]

(d) Time integration
\[ \mathcal{L}\left[ \int_{t_0}^{t} f(t') \, dt' \right] = \frac{1}{s} F(s) \]

(e) Time shift
\[ \mathcal{L}[f(t - t_0)] = F(s) e^{-st_0} \]

(f) Time scaling
\[ \mathcal{L}[f(at)] = \frac{1}{a} F\left(\frac{s}{a}\right) \]

(g) Damping
\[ \mathcal{L}[e^{-st} f(t)] = F(s + s_0) \]

(h) Multiplication
\[ \mathcal{L}[t^n f(t)] = (-1)^n F^{(n)}(s) \]

(i) Initial value if \( f(t) = 0 \) for \( t < 0 \)
\[ f(0^+) = \lim_{s \to \infty} sF(s) \]

(j) Final value
\[ f(\infty) = \lim_{s \to 0} sF(s) \]

(k) Parseval’s theorem
\[ \int_{-\infty}^{\infty} |f(t)|^2 \, dt = \int_{-\infty}^{\infty} |F(i2\pi f)|^2 \, df = 2\int_0^{\infty} |F(i2\pi f)|^2 \, df \]
Performing the Laplace Transform of the quasi-static equation

\[ \nabla \left[ \varepsilon(x) \nabla \frac{\partial \varphi(x,t)}{\partial t} + \sigma(x) \nabla \varphi(x,t) \right] = -\frac{\partial \rho_e(x,t)}{\partial t} \]

we find

\[ \nabla \left[ \varepsilon(x) \nabla s \varphi(x,s) + \sigma(x) \nabla \varphi(x,s) \right] = -s \rho_e(x,s) \]

\[ \nabla \left[ (\varepsilon(x) + \sigma(x)/s) \nabla \varphi(x,s) \right] = -\rho_e(x,s) \]

So we can write this equation as

\[ \nabla [\varepsilon_{eff}(x) \nabla \varphi(x,s)] = -\rho_e(x,s) \]

\[ \varepsilon_{eff}(x) = \varepsilon(x) + \sigma(x)/s \]

\[ \rho(x,s) = -\nabla [\varepsilon(x) \nabla \varphi(x,s)] \]

\[ \rho_e(x,s) = -\nabla [\varepsilon_{eff}(x) \nabla \varphi(x,s)] \]

This is the Poisson equation with an effective permittivity !!

→ We can therefore find the time dependent solutions for a medium with a given conductivity by solving the electrostatic Poisson equation in the Laplace domain !

→ Knowing the electrostatic solution for a given permittivity \( \varepsilon(x) \) we just have to replace \( \varepsilon(x) \) by \( \varepsilon(x) + \sigma(x)/s \) and perform the inverse Laplace transform !
Electric fields, weighting fields, signals and charge diffusion in detectors including resistive materials

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ABSTRACT: In this report we discuss static and time dependent electric fields in detector geometries with an arbitrary number of parallel layers of a given permittivity and weak conductivity. We derive the Green’s functions i.e. the field of a point charge, as well as the weighting fields for readout pads and readout strips in these geometries. The effect of ‘bulk’ resistivity on electric fields and signals is investigated. The spreading of charge on thin resistive layers is also discussed in detail, and the conditions for allowing the effect to be described by the diffusion equation is discussed. We apply the results to derive fields and induced signals in Resistive Plate Chambers, MICROMEGAS detectors including resistive layers for charge spreading and discharge protection as well as detectors using resistive charge division readout like the MicroCAT detector. We also discuss in detail how resistive layers affect signal shapes and increase crosstalk between readout electrodes.
A point charge $Q$ at $x=0$ inside a medium of constant permittivity $\varepsilon$

$$\rho(x) = Q\delta(x) \quad \varphi(x) = \frac{Q}{4\pi \varepsilon |x|} \quad \varepsilon = \varepsilon_0\varepsilon_r$$

A point charge $Q$ placed at $x=0$ into a medium of constant permittivity $\varepsilon$ and constant conductivity $\sigma$

$$\rho_e(x, t) = Q\delta(x) \Theta(t) \quad \rho_e(x, s) = L[\rho_e(x, t)] = \frac{Q}{s} \delta(x)$$

$$\varphi(x, s) = \frac{Q/s}{\varepsilon + \sigma/s |x|} = \frac{Q}{(s + 1/\tau)} \frac{1}{4\pi \varepsilon |x|} \quad \tau = \frac{1}{\sigma} = \frac{\varepsilon_0}{\varepsilon}$$

$$\varphi(x, t = 0) = \lim_{s \to \infty} s\varphi(x, s) = \frac{Q}{4\pi \varepsilon |x|} \quad \varphi(x, t = \infty) = \lim_{s \to 0} s\varphi(x, s) = 0$$

At $t=0$ when the charge is placed at $x=0$, the potential is equal to the static potential in absence of conductivity, for long times the potential is zero.

The time dependent potential is:

$$\varphi(x, t) = L^{-1}[\varphi(x, s)] = \frac{Q}{4\pi \varepsilon |x|} e^{-t/\tau}$$
The charge density is given by

\[ \rho(x, s) = -\nabla [\varepsilon(x) \nabla \varphi(x, s)] = -\varepsilon \Delta \varphi(x, s) = \frac{Q \delta(x)}{s + 1/\tau} \]

In the time domain we have

\[ \rho(x, t) = Q\delta(x)e^{-t/\tau} \]

The situation therefore corresponds to a and exponentially decaying point charge at \( x=0 \). The radial current are given by

\[ j(x, s) = \sigma E(x, s) = -\sigma \nabla \varphi(x, s) = -\frac{1}{\tau \left(s + 1/\tau\right)} \nabla \frac{1}{4\pi |x|} \]

The total current flowing through the surface of a sphere of radius \( r \) is

\[ I(s, r) = \oint_{S(r)} j(x, s) dA = \int_V \nabla j dV = \int_V \nabla \frac{1}{4\pi |x|} dV = \frac{1}{\tau \left(s + 1/\tau\right)} \int_V \Delta \frac{1}{4\pi |x|} dV = \frac{Q}{\tau \left(s + 1/\tau\right)} \]

In the time domain this reads as

\[ I(t, r) = L^{-1} [I(s, r)] = \frac{Q}{\tau} e^{-t/\tau} \]

Integrating this current over time gives

\[ Q_{\text{tot}} = \int_0^{\infty} I(t, r) dt = \lim_{s \to 0} \frac{1}{s} I(s, t) = Q \]

This reflects the fact that the entire charge that was place at \( x=0 \) at \( t=0 \) disappears.
Placing a constant current $I_0$ at $x=0$ at $t=0$ we have the charge

$$Q(t) = I_0 t \quad Q(s) = \int_0^s Q(t) = \frac{I_0}{s^2}$$

and the potential is then

$$\varphi(x, s) = \frac{I_0}{s^2 \epsilon + \sigma/s} \frac{1}{4\pi|x|} = \frac{I_0}{s(s + 1/\tau)} \frac{1}{4\pi \epsilon |x|} = I_0 \tau \left( \frac{1}{s} - \frac{1}{s + 1/\tau} \right) \frac{1}{4\pi \epsilon |x|} \quad \tau = \frac{\epsilon}{\sigma} = \frac{\epsilon \tau \sigma}{\sigma}$$

For long times we then have

$$\varphi(x, t = \infty) = \lim_{s \to 0} s \varphi(x, s) = I_0 \tau \frac{1}{4\pi \epsilon |x|}$$

So the potential is equal to having a point charge $I_0 \tau$ at $x=0$. The time dependent potential is

$$\varphi(x, t) = I_0 \tau (1 - e^{-t/\tau}) \frac{1}{4\pi \epsilon |x|}$$
Point charge \( Q \) on the boundary of two media

Point charge \( Q \) at \( x=0 \) on the boundary between two infinite half-spaces of different permittivity

\[
\varphi(x) = \frac{Q}{2\pi(\varepsilon_1 + \varepsilon_2)} \frac{1}{|x|}
\]

Placing a point charge \( Q \) placed at \( t=0 \) at \( x=0 \) on the boundary between two half-spaces of different permittivity and conductivity, Laplace domain

\[
\varphi(x, s) = \frac{Q}{2\pi(\varepsilon_1 + \varepsilon_2)(s + 1/\tau)} \frac{1}{|x|} \quad \tau = \frac{\varepsilon_1 + \varepsilon_2}{\sigma_1 + \sigma_2}
\]

Time domain

\[
\varphi(x, t) = \frac{Q}{2\pi(\varepsilon_1 + \varepsilon_2)} \frac{1}{|x|} e^{-t/\tau}
\]

The current flowing through a half-spheres in the two layers are given by

\[
I_1(t) = \sigma_1 |\mathbf{E}(r, t)| 2r^2 \pi = \frac{\sigma_1 Q}{(\varepsilon_1 + \varepsilon_2)} e^{-t/\tau} \quad I_2(t) = \sigma_2 |\mathbf{E}(r, t)| 2r^2 \pi = \frac{\sigma_2 Q}{(\varepsilon_1 + \varepsilon_2)} e^{-t/\tau}
\]

\[
Q_1 = \int_0^\infty I_1(t) dt = \frac{\sigma_1}{\sigma_1 + \sigma_2} Q \quad Q_2 = \int_0^\infty I_2(t) dt = \frac{\sigma_2}{\sigma_1 + \sigma_2} Q \quad Q_1 + Q_2 = Q
\]
Thin layer of charge on the boundary of two media

An infinite thin layer of charge at z=0 with charge density $q$ [C/cm$^2$] on the boundary of two infinite dielectric half-spaces

$$E = \frac{q}{\varepsilon_1 + \varepsilon_2}$$

Placing the charge density $q$ at t=0 with the two infinite half-spaces having a conductivities $\sigma_1$ and $\sigma_2$

$$E(s) = \frac{q}{(\varepsilon_1 + \varepsilon_2)(s + 1/\tau)} \quad \tau = \frac{\varepsilon_1 + \varepsilon_2}{\sigma_1 + \sigma_2}$$

$$E(t) = \frac{q}{(\varepsilon_1 + \varepsilon_2)} e^{-t/\tau}$$

The time dependent charge on the interface is

$$\varepsilon_1 E(t) + \varepsilon_2 E(t) = \bar{q}(t) \quad \rightarrow \quad \bar{q}(t) = q e^{-t/\tau}$$

In case the half-space z<0 has conductivity $\sigma$ and the half-space z>0 is insulating the time constant is

$$\tau = \frac{\varepsilon_0}{\sigma} (\varepsilon_r + 1)$$
Point charge $Q$ in presence of a conducting half-space

Point charge $Q$ at position $0,0,a$ in a geometry with two infinite half-spaces of different dielectric permittivities

$$\varphi(x) = \frac{Q}{4\pi\varepsilon_2} \left[ \frac{1}{\sqrt{x^2 + y^2 + (z-a)^2}} - \frac{1}{\varepsilon_1 - \varepsilon_2} \frac{1}{\varepsilon_2 + \varepsilon_3} \frac{1}{\sqrt{x^2 + y^2 + (z+a)^2}} \right] \quad z > 0$$

$$\varphi(x) = \frac{Q}{4\pi\varepsilon_2 \varepsilon_1 + \varepsilon_2} \frac{1}{\sqrt{x^2 + y^2 + (z-a)^2}} \quad z < 0$$

Point charge $Q$ at position $0,0,0$ in a geometry with an infinite half-space of conductivity $\sigma$. Replace $\varepsilon_2$ by $\varepsilon_0$, $\varepsilon_1$ by $\varepsilon_0 + \sigma/s$ and $Q$ by $Q/s$

$$\varphi(x, t) = \frac{Q}{4\pi\varepsilon_0 \sqrt{x^2 + y^2 + (z-a)^2}} - \frac{Q(1 - e^{-t/\tau})}{4\pi\varepsilon_0 \sqrt{x^2 + y^2 + (z+a)^2}} \quad z > 0$$

$$\varphi(x, t) = \frac{Qe^{-t/\tau}}{4\pi\varepsilon_0 \sqrt{x^2 + y^2 + (z-a)^2}} \quad z < 0 \quad \tau = 2\varepsilon_0/\sigma$$

At $t=0$ the field is equal to a single point charge $Q$ at $0,0,a$. At $t=\infty$ there is a point charge $Q$ at $0,0,a$ and a mirror charge at $0,0,-a$. 
Layer of charge on the boundary between two dielectric layers and two grounded plates at $z=-b$ and $z=g$.

\[ E_1 b + E_2 g = 0 \quad -\varepsilon_1 E_1 + \varepsilon_2 E_2 = q \]

\[
E_1 = -\frac{gq}{\varepsilon_1 g + \varepsilon_2 b} \quad E_2 = \frac{bq}{\varepsilon_1 g + \varepsilon_2 b}
\]

Replace $\varepsilon_1$ by $\varepsilon_0 \varepsilon_r + \sigma/s$, $\varepsilon_2$ by $\varepsilon_0$ and $q$ by $q/s$

\[
E_1(t) = -\frac{gq}{\varepsilon_1 g + \varepsilon_2 b} e^{-t/\tau} \quad E_2(t) = \frac{bq}{\varepsilon_1 g + \varepsilon_2 b} e^{-t/\tau} \quad \tau = \frac{\varepsilon_0}{\sigma} \left( \varepsilon_r + \frac{b}{g} \right)
\]

In case $b=g$ the time constant becomes equal to the case of two infinite half-spaces.
Quasi-static Approximation of Maxwell’s equations

Point charge on the boundary of two dielectric media with grounded planes at $z=-b$ and $z=g$

\[
\phi_1(r,z) = \frac{Q}{2\pi} \int_0^{\infty} J_0(kr) \frac{4\sinh(gk) \sinh(k(b+z))}{D(k)} \, dk - b < z < 0
\]

\[
\phi_2(r,z) = \frac{Q}{2\pi} \int_0^{\infty} J_0(kr) \frac{4\sinh(bk) \sinh(k(g-z))}{D(k)} \, dk \quad 0 < z < g
\]

\[
D(k) = 4[\varepsilon_1 \cosh(bk) \sinh(gk) + \varepsilon_2 \sinh(bk) \cosh(gk)]
\]

Assuming layer 1 to have conductivity $\sigma$ we have

\[
\varepsilon_1 = \varepsilon_0 \varepsilon_r + \sigma/s \quad \varepsilon_2 = \varepsilon_0 \quad Q_1 = Q/s \quad (4.14)
\]

\[
E_1(r,z,t) = -\frac{Q}{2\pi} \int_0^{\infty} k J_0(kr) \frac{\sinh(gk) \cosh(k(b+z))}{\varepsilon_0[\sinh(bk) \cosh(gk) + (\varepsilon_r + \sigma/\varepsilon_0s) \cosh(bk) \sinh(gk)]} \, dk \quad (4.15)
\]

\[
E_2(r,z,t) = \frac{Q}{2\pi s} \int_0^{\infty} k J_0(kr) \frac{\sinh(bk) \cosh(k(g-z))}{\varepsilon_0[\sinh(bk) \cosh(gk) + (\varepsilon_r + \sigma/\varepsilon_0s) \cosh(bk) \sinh(gk)]} \, dk
\]

We find the time dependent fields by performing the inverse Laplace transforms and have

\[
E_1(r,z,t) = -\frac{Q}{2\pi} \int_0^{\infty} k J_0(kr) \frac{\sinh(gk) \cosh(k(b+z))}{\varepsilon_0 D(k)} e^{-t/\tau(k)} \, dk \quad (4.16)
\]

\[
E_2(r,z,t) = \frac{Q}{2\pi} \int_0^{\infty} k J_0(kr) \frac{\sinh(bk) \cosh(k(g-z))}{\varepsilon_0 D(k)} e^{-t/\tau(k)} \, dk
\]

with

\[
\tau(k) = \frac{\varepsilon_0}{\sigma} \left( \frac{\varepsilon_r + \tanh(bk)}{\tanh(gk)} \right)
\]
The charge disappears with a continuous distribution of time constants of $\tau_1$ and $\tau_2$.
This situation would correspond to a charge deposit in a Resistive Plate Chamber (RPC).
Point current on a resistive layers

\[ i_0(r) = -\sigma E_1(r, z = -b) = \frac{i_0}{b^2 \pi} \int_0^\infty \frac{1}{2} J_0 \left( \frac{y}{b} \right) \frac{y}{\cosh(y)} \, dy \]

\[ \int_0^\infty \frac{1}{2} J_0 \left( \frac{y}{b} \right) \frac{y}{\cosh(y)} \, dy = \frac{\pi}{2} \sum_{n=0}^{\infty} (-1)^n (2n + 1) K_0 \left( \frac{(2n + 1) \pi r}{2b} \right) \approx \frac{\pi}{2 \sqrt{r/b}} \, e^{-\pi r/(2b)} \quad \text{for} \quad \frac{r}{b} \gg 1 \]

\[ I(r) = \int_0^r 2 \pi i_0(r') \, dr' = l_0 \left[ 1 - 2 \sum_{n=0}^{\infty} (-1)^n \frac{r}{b} K_1 \left( \frac{(2n + 1) \pi r}{2b} \right) \right] \]

Figure 12. a) Current density \( i_0(r) \) at \( z = -b \). The exact curve together with the 2\textsuperscript{nd} order and 4\textsuperscript{th} order approximation from eq. (4.20) and the exponential approximation from eq. (4.22). b) Total current at \( z = -b \) flowing inside a radius \( r \) from eq. (4.23).
A point charge \( Q \) is placed on an infinitely extended resistive layer at \( r=0, t=0 \). The potential for \( z>0 \) and \( z<0 \) is given by

\[
\phi_1(r, z, t) = \frac{Q}{4\pi \varepsilon_0} \frac{1}{\sqrt{r^2 + (-z + vt)^2}} \quad \phi_3(r, z, t) = \frac{Q}{4\pi \varepsilon_0} \frac{1}{\sqrt{r^2 + (z + vt)^2}}
\]

The potential is equivalent to a point charge \( Q \) moving along the \( z \)-axis at a velocity \( v \)

The charge distribution on the resistive layer as a function of time is

\[
q(r, t) = \varepsilon_0 \frac{\partial \phi_1}{\partial z} |_{z=0} - \varepsilon_0 \frac{\partial \phi_3}{\partial z} |_{z=0} = \frac{Q}{2\pi} \frac{vt}{\sqrt{(r^2 + vt^2)^3}}
\]

At no time this charge distribution assumes a Gaussian shape.
A resistive layer in presence of a grounded layer. A point charge is placed on the layer at $r=0$, $t=0$

$$q(r, t) = \frac{Q}{b^2 \pi} \frac{1}{2} \int_0^\infty \kappa J_0 \left( \kappa \frac{r}{b} \right) \exp \left[ -\kappa \left( 1 - e^{-2\kappa} \right) \frac{t}{T} \right] \, dk$$

$$T = \frac{b}{v} = 2b\varepsilon_0 R$$

For long times we can make the approximation

$$-\kappa \left( 1 - e^{-2\kappa} \right) \frac{t}{T} \approx -2\kappa^2 \frac{t}{T}$$

And the charge distribution becomes

$$q(r, t) = \frac{Q}{b^2 \pi} \frac{1}{8t/T} e^{-\frac{r^2}{8b^2 t/T}}$$

The charge distribution does indeed assume Gaussian shape …
Capacitance, Impedance

A constant voltage applied to a capacitor with homogeneous dielectric permittivity

\[ \varphi(z) = \frac{V}{d} z \]

\[ Q_1 = -\varepsilon \frac{V_0}{d} A \quad Q_2 = \varepsilon \frac{V_0}{d} A \]

A time dependent voltage applied to a capacitor with conductive material

\[ Q_1(s) = -\varepsilon \frac{V(s)}{d} A \quad Q_2(s) = \varepsilon \frac{V(s)}{d} A \]

\[ I_2(s) = \sigma \frac{V(s)}{d} A \]

\[ \frac{dQ_2(t)}{dt} = -I_2(t) + I(t) \]

\[ I(s) = sQ_2(s) + I_2(s) = \left( s\varepsilon \frac{A}{d} + \sigma \frac{A}{d} \right) V(s) = \left( sC + \frac{1}{R} \right) V(s) = \frac{V(s)}{Z(s)} \]

\[ Z(s) = \frac{\frac{1}{sC} R}{\frac{1}{sC} + R} \]
Quasi-static Approximation of Maxwell’s equations

A constant voltage applied to a geometry with two insulating layers

\[-E_1 b - E_2 g = V_0 \quad -\varepsilon_1 E_1 + \varepsilon_2 E_2 = 0\]

\[E_1 = -\frac{\varepsilon_2 V_0}{\varepsilon_1 g + \varepsilon_2 b} \quad E_2 = -\frac{\varepsilon_1 V_0}{\varepsilon_1 g + \varepsilon_2 b}\]

\[Q_1 = \varepsilon_1 E_1 A = -\frac{\varepsilon_1 \varepsilon_2 A V_0}{\varepsilon_1 g + \varepsilon_2 b} \quad Q_2 = -\varepsilon_2 E_2 A = \frac{\varepsilon_1 \varepsilon_2 A V_0}{\varepsilon_1 g + \varepsilon_2 b}\]

\[Q_1 = -CV_0 \quad Q_2 = CV_0 \quad C = \frac{C_1 C_2}{C_1 + C_2} \quad C_1 = \frac{\varepsilon_1 A}{b} \quad C_1 = \frac{\varepsilon_2 A}{g}\]

A time dependent voltage applied to a geometry with an insulating and a conductive layer

\[E_2(s) = -\frac{(\varepsilon_0 \varepsilon_r s + \sigma)V(s)}{(b + \varepsilon_r g)\varepsilon_0 s + g\sigma} \quad Q_2 = -\varepsilon_0 E_2(s) A\]

\[I(s) = s Q_2 = \frac{V(s)}{Z(s)} \quad Z(s) = \frac{R + \frac{1}{sC_1}}{R + \frac{1}{sC_1} + \frac{1}{sC_2}}\]

\[C_1 = \varepsilon_0 \varepsilon_r \frac{A}{b} \quad C_2 = \varepsilon_0 \frac{A}{g} \quad R = \frac{1}{b} \frac{1}{\sigma A}\]
N+1 metal electrodes at potentials $V_n$ will result in charges $Q_n$ on the electrodes.

Using the weighting potential for each electrode

$$\nabla [\varepsilon(\mathbf{x}) \nabla \psi_n(\mathbf{x})] = 0 \quad \psi_n(\mathbf{x})|_{\mathbf{x} = A_n} = V_w \delta_{mn}$$

we can construct the solution to the problem

$$\varphi(\mathbf{x}) = \sum_m \frac{V_m}{V_w} \psi_m(\mathbf{x})$$

Inserting this in the above relation results in

$$Q_n = \sum_m \frac{V_m}{V_w} \int_{A_n} \varepsilon(\mathbf{x}) \nabla \psi_m(\mathbf{x}) d\mathbf{A} = c_{nm} V_m$$

$$c_{mn} = \frac{1}{V_w} \int_{A_n} \varepsilon(\mathbf{x}) \nabla \psi_m(\mathbf{x}) d\mathbf{A}$$

This defines the capacitance matrix of the system.
Admittance matrix for conductive media

N+1 metal electrodes at potentials $V_n$ will result in charges $Q_n$ on the electrodes.

Using the weighting potential for each electrode we can construct the solution to the problem

Inserting this in the above relation results in

This defines the ‘admittance’ matrix of the system:
Impedance Matrix

As in the case of the capacitance matrix we define one electrode as the reference electrode in order to have a unique relation between currents and voltages

\[ U_n(s) = V_n(s) - V_0(s) \]

The matrix \( y_{mn}(s) \) is the Impedance Matrix of the system

\[ i_n^{\text{ext}}(s) = \sum_{m=1}^{N} y_{nm}(s) U_m(s) \]

\[ U_n(s) = \sum_{m=1}^{N} z_{nm}(s) i_m^{\text{ext}}(s) \]

\[ z_{mn} = y_{mn}^{-1} \]

The matrix \( y_{mn} \) the Admittance Matrix of the system

The matrix \( z_{mn} \) is the Impedance Matrix of the system

\[ y_{mn}(s) = \frac{s}{V_w} \int_{A_n} \varepsilon_{\text{eff}}(x, s) \nabla \psi_m(x, s) dA \]
Signals in Particle Detectors, W. Riegler/CERN

The impedance elements of the equivalent circuit are defined by

\[ i_{nn}(s) = \frac{U_n(s)}{Z_{nn}(s)} \]
\[ i_{nm}(s) = \frac{U_n(s) - U_m(s)}{Z_{mn}(s)} \]

Using the fact that the sum of these currents at each node is zero

\[ i_{n}^{\text{ext}}(s) = \sum_{m=1}^{N} i_{nm}(s) \]

we can relate the impedance elements \( Z_{mn} \) to the Admittance Matrix \( y_{mn} \)

\[ Z_{mn}(s) = -\frac{1}{y_{nm}(s)} \quad n \neq m \]
\[ Z_{nn}(s) = \frac{1}{\sum_{m=1}^{N} y_{nm}(s)} = -\frac{1}{y_{0n}} \quad n = m \]
Signals in Particle Detectors, W. Riegler/CERN

The weighting field of electrode 1

\[ E_1^{\text{w}}(s) = -\frac{s\varepsilon_0 V_w}{\varepsilon_0 s (b + \varepsilon_r g) + g\sigma} \]

Using the general formula for the impedance matrix

\[ y_{mn}(s) = \frac{s}{V_w} \int_{\mathcal{A}_n} \varepsilon_{eff}(x,s) \nabla \psi_m(x,s) dA \]

we have

\[ y_{10} = \frac{s}{V_w} A \left( \varepsilon_0 \varepsilon_r + \frac{\sigma}{s} \right) E_1^{\text{w}}(s) = \frac{1}{Z_{11}(s)} \]

\[ Z_{11}(s) = \frac{R \frac{1}{sC_1}}{R + \frac{1}{sC_1}} + \frac{1}{sC_2} \]

\[ C_1 = \varepsilon_0 \varepsilon_r \frac{A}{b} \quad C_2 = \varepsilon_0 \frac{A}{g} \quad R = \frac{1}{\sigma} \frac{b}{A} \]
The weighting potentials in the Laplace domain are due to application of $V_w$ to the electrode in question and grounding all the others.

In the time domain this refers to a delta function $V_w \delta(t)$ applied to the electrode in question.
Extension of the Ramo Shockley theorem


Theorem, induced charge

The charge induced on a grounded conducting electrode by a point charge $q$ at position $x$ can be calculated the following way:

Remove the point charge, put the electrode in question to potential $V_w$ while keeping all other electrodes at ground potential.

This defines the potential $\psi_n(x)$ and the induced charge is

$$Q_n^{ind} = -\frac{q}{V_w} \psi_n(x)$$
Theorem, induced charge

The charge induced on a grounded conducting electrode by a point charge \( q(s) \) at position \( x \) can be calculated the following way:

Remove the point charge, apply a voltage \( V_w(s) \) to the electrode in question while keeping all other electrodes at ground potential

\[
Q_{n}(s) = Q_{ext}(s) = -\frac{q(s)}{V_w(s)} \psi_n(x, s)
\]

\[
Q^{ind}(t) = L^{-1} [Q^{ind}(s)]
\]

Note that this charge does not refer to the charge that is sitting on the electrode but to the charge that is brought into the system i.e. the charge that has moved between ground and the electrode.

That’s exactly that charge one measures if one connects an amplifier to the electrode.
Theorem, induced charge

In case we have a time varying external charge density in between the electrodes we have

\[ Q_{ext}^{ind}(s) = -\frac{1}{V_w(s)} \int_V \psi_n(x, s) \rho_e(x, s) d^3x \quad Q^{ind}(t) = \mathbf{L}^{-1} [Q^{ind}(s)] \]

In case we chose to apply a delta function for finding the weighting field we have

\[ Q_{ext}^{ind}(s) = -\frac{1}{V_w} \int_V \psi_n(x, s) \rho_e(x, s) d^3x \quad Q^{ind}(t) = \mathbf{L}^{-1} [Q^{ind}(s)] \]

\[ Q_{ext}^{ind}(t) = \frac{1}{V_w} \int_0^t \int \psi_n(x, t - t') \rho_e(x, t') d^3x dt \]

If there is a charge moving along a trajectory \( x_1(t) \) the charge density amounts to

\[ \rho_e(x, t) = q \delta(x - x_1(t)) \]

And the induced charge is

\[ Q_{ext}^{ind}(t) = -\frac{q}{V_w} \int_0^t \psi_n(x_1(t'), t - t') d^3x dt \]

Note that \( \psi_n \) is not a physical potential, since the delta function gives it a dimension of V/s.
Theorem, induced current

Applying the delta voltage pulse to the electrode in question we find the potential $\psi_n(x, t)$ and the field $E_n(x, t)$ from which the induced current can be calculated the following way:

$$I_n^{\text{ext}}(t) = -sQ_n^{\text{ext}}(s) = \frac{s}{V_w} \int_V \psi_n(x, s) \rho_e(x, s) d^3x$$

$$\rho_e(x, t) = q\delta(x - x_1(t))$$

$$I_n^{\text{ext}}(t) = -\frac{q}{V_w} \int_0^t E_n(x_1(t'), t - t') \dot{x}_1(t') dt'$$

$\rightarrow$ Ramo-Shockley theorem extension for conducting media

Note that $E_n$ is not physical potential, since the delta function gives it a dimension of $\text{V/cm s}$.

In case the material is an insulator there is no time dependence of the weighting field and we recuperate Ramo’s theorem.

$$E_n(x, t) = E_{n0}(x) \delta(t - t')$$

$$I_n^{\text{ext}}(t) = -\frac{q}{V_w} E_{n0}(x_1(t)) \dot{x}_1(t) dt$$
Example

**RPC**

- $\varepsilon_r \approx 6$, $\rho \approx 1/\sigma \approx 10^{12} \Omega \text{cm}$
- 2mm Aluminum
- 3mm Glass
- 300$\mu$m Gas Gap
- $\tau \approx \varepsilon_0 / \sigma \approx 100 \text{msec}$

$R_{in}$

**Silicon Detector**

- $\rho = 1/\sigma \approx 5 \times 10^3 \Omega \text{cm}$
- Depleted Zone
- Undepleted Zone
- $\tau \approx \varepsilon_0 / \sigma \approx 1 \text{ns}$

Heavily irradiated silicon has larger resistivity that can give time constants of a few hundreds of ns
Weighting Field of Electrode 1

\[
E_{1z}(s) = \frac{\varepsilon_a V_0}{\varepsilon_a d_2 + \varepsilon_b d_1} = \frac{V_0 \varepsilon_r}{(d_1 + d_2 \varepsilon_r) s + \frac{1}{r_1}} \quad z > 0
\]

\[
= \frac{\varepsilon_b V_0}{\varepsilon_a d_2 + \varepsilon_b d_1} = \frac{V_0}{(d_1 + d_2 \varepsilon_r) s + \frac{1}{r_2}} \quad z < 0
\]

\[
\tau_1 = \frac{\varepsilon_r \varepsilon_0}{\sigma} \quad \tau_2 = \frac{\varepsilon_0}{\sigma} \left( \frac{d_1 + d_2 \varepsilon_r}{d_2} \right)
\]

Weighting Field of Electrode 2

\[
E_{2z}(s) = -E_{1z}(s)
\]
At $t=0$ a pair of charges $q$, $-q$ is created at $z=d_2$. One charge is moving with velocity $v$ to $z=0$. Until it hits the resistive layer at $T=d_2/v$.

\[ x_0(t) = \begin{cases} d_2 - vt & t < T \\ 0 & t > T \end{cases} \]

\[ \dot{x}_0(t) = \begin{cases} -v & t < T \\ 0 & t > T \end{cases} \]

\[ E_{1z}(x, t) = \frac{\varepsilon_r V_0}{d_1 + \varepsilon_r d_2} \left[ \delta(t) + \frac{\tau_2 - \tau_1}{\tau_1 \tau_2} e^{-\frac{t}{\tau_2}} \right] \quad z > 0 \]

\[ I_1(t) = \begin{cases} qv \frac{\varepsilon_r}{d_1 + \varepsilon_r d_2} \left[ 1 + \frac{d_1}{d_2 \varepsilon_r} (1 - e^{-\frac{t}{\tau_2}}) \right] & t < T \\ qv \frac{1}{d_1 + \varepsilon_r d_2} \frac{d_1}{d_2} \left( \frac{T}{e^{\tau_2} - 1} \right) e^{-\frac{t}{\tau_2}} & t > T \end{cases} \]
In case of high resistivity (τ >> T, RPCs, irradiated silicon) the layer is an insulator.

In case of very low resistivity (τ << T, silicon) the layer acts like a metal plate and the scenario is equal to a parallel plate geometry with plate separation d₂.

The total induced charge is always equal to q!

\[ \int_{0}^{\infty} I_1(t) dt = q \]
What is the effect of a conductive layer between the readout strips and the place where a charge is moving?
Strip Example

\[ \varepsilon_3 = \varepsilon_0 \]

\[ \varepsilon_2 = \varepsilon_0 + \sigma/S \]

\[ \varepsilon_1 = \varepsilon_0 \]

\[ V_0 \]

Electrostatic Weighting field (derived from B. Schnizer et. al, CERN-OPEN-2001-074):

\[ E_z(x, z) = \frac{41}{\pi} \int_0^{\infty} \frac{dz \cos(\omega z) \sin \left( \frac{w}{2} \right)}{z^2 + (\varepsilon_1 + \varepsilon_2 + \varepsilon_3) \sinh[\alpha (p + q)] - (\varepsilon_1 - \varepsilon_2)(\varepsilon_2 + \varepsilon_3) \sinh[\alpha (q - p)] - (\varepsilon_1 + \varepsilon_2)(\varepsilon_2 - \varepsilon_3) \sinh[\alpha(2q + p - q)] + (\varepsilon_1 - \varepsilon_2)(\varepsilon_2 - \varepsilon_3) \sinh[\alpha(p + q - 2q)]} \]

Replace \( \varepsilon_1 \rightarrow \varepsilon_0, \varepsilon_2 \rightarrow \varepsilon_0 + \sigma/S, \varepsilon_3 \rightarrow \varepsilon_0 \) and perform inverse Laplace Transform

\( \rightarrow E_z(x, z, t) \). Evaluation with MATHEMATICA:
Strip Example

T<<\tau
T=\tau
T=10\tau
T=50\tau
T=500\tau

The conductive layer ‘spreads’ the signals across the strips.

\[ \tau = \frac{\varepsilon_0}{\sigma} \]

\[ I_1(t) \quad I_3(t) \quad I_5(t) \]
Charge spreading

In some detectors, a resistive layer is applied on top of the readout strips to spread out the charge and therefore ‘increase’ the pad response function.

This example shows a resistive ‘bulk’ layer on top of the readout strips. The layer is in contact with the strips, so charge can move from the strips into the resistive layer.

- The solid blue line shows the situation for the given time constant.
- The dashed blue line shows the situation for zero conductivity
- The dashed magenta line shows the situation for infinite conductivity
**Charge spreading**

\[ T_0 = \varepsilon_0 Rg \quad T = g/v \]

In some detectors, a resistive layer is applied on top of the readout strips to spread out the charge and therefore 'increase' the pad response function.

This example shows a thin resistive layer on top of the readout strips. The layer is insulated from the strips.

- The solid line shows the situation for different time constants
- The dashed line shows the situation for infinite resistivity

For different time constants:
- \( T_0 = 10T \)
- \( T_0 = T \)
- \( T_0 = 0.1T \)
- \( T_0 = 0.01T \)
- \( T_0 = 0.001T \)

Figure 34. \( \varepsilon_x = 1, w_x = 4g, b = g, T_0 = 10T \) for \( x = 0, x = 4g, x = 8g \).

Figure 35. \( \varepsilon_x = 1, w_x = 4g, b = g, T_0 = T \) for \( x = 0, x = 4g, x = 8g \).

Figure 36. \( \varepsilon_x = 1, w_x = 4g, b = g, T_0 = 0.1T \) for \( x = 0, x = 4g, x = 8g \).

Figure 37. \( \varepsilon_x = 1, w_x = 4g, b = g, T_0 = 0.01T \) for \( x = 0, x = 4g, x = 8g \).

Figure 38. \( \varepsilon_x = 1, w_x = 4g, b = g, T_0 = 0.001T \) for \( x = 0, x = 4g, x = 8g \).
Induced voltage, equivalent circuit
Theorem, induced voltage, static

The voltage induced on an uncharged and insulated conducting electrode by a point charge $q$ at position $x$ can be calculated the following way:

Remove the point charge, put a charge $Q_w$ on the electrode in question while keeping all other electrodes insulated and uncharged.

This defines the potential $\chi_n(x)$ and the induced voltage is

$$V_{n}^{ind}(t) = \frac{q}{Q_0} \chi_n(x(t))$$
Applying the delta voltage pulse to the electrode in question we find the potential \( \psi_n(x, t) \) and the field \( E_n(x, t) \) from which the induced current can be calculated the following way:

\[
V_n^{ind}(s) = \frac{s}{Q_w} \int_V \chi_n(x, s) \rho_c(x, t) d^3x
\]

\[
\rho_c(x, t) = q \delta(x - x_1(t))
\]

\[
V_n^{ind}(s) = -\frac{q}{Q_w} \int_0^t K(x_1(t'), t - t') \dot{x}_1(t') dt'
\]

Since the admittance matrix relates currents and voltages on the electrodes in absence of charge, the admittance matrix relates the weighting fields \( E_n \) and \( K_n \) and therefore related the currents induced on grounded electrodes and the voltages induced on insulated electrodes.

\[
I_n^{ind}(s) = \sum_{n=1}^N y_{nm}(s) V_m^{ind}(s)
\]

This means in turn that we can first calculate the current induced on grounded electrodes and then place these currents as ideal current sources on the equivalent circuit of the medium.
Equivalent circuit, Impedance elements

\[
Z_{nm}(s) = \begin{cases} 
\frac{1}{y_{nm}(s)} & n \neq m \\
\frac{1}{\sum_{m=1}^{N} y_{nm}(s)} & n = m 
\end{cases}
\]

\[
y_{mn}(s) = \frac{s}{V_w} \int_{A_m} \epsilon_{eff}(x, s) \nabla \psi_m(x, s) dA
\]
In case the electrodes are not insulated but connected with discrete linear impedance components we can consider them as part of the medium and we therefore just have to add these elements in the equivalent circuit.

$$Z_{nm}(s) = \frac{1}{y_{nm}(s)} \quad n \neq m \quad Z_{nn}(s) = \frac{1}{\sum_{m=1}^{N} y_{nm}(s)} = -\frac{1}{y_{0n}} \quad n = m$$

$$y_{mn}(s) = \frac{s}{V_w} \int_{A_n} \varepsilon_{eff}(\mathbf{x}, s) \nabla \psi_m(\mathbf{x}, s) d\mathbf{A}$$
Nonlinear media


An application of extensions of the Ramo–Shockley theorem to signals in silicon sensors

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Metal electrodes embedded in a medium with

- Static space-charge $\rho_0(x)$
- Position and frequency dependent permittivity $\varepsilon(x, s)$
- Position and frequency dependent conductivity $\sigma(x, s) = 1/\rho(x,s)$ ($\rho$ ... volume resistivity)
- Connection of the electrodes with discrete impedance elements $z_{mn}(s)$
- Nonlinear material i.e. $\rho_0(x)$, $\varepsilon(x, s)$, $\sigma(x, s)$ can depend on the voltages $V_n$ applied to the electrodes.

$\Rightarrow$ Silicon sensor !
Induce voltage

This weighting field is defined by placing a ‘step charge’ or ‘delta current’ on the electrode in question and calculating the resulting electric field.

This theorem is very well suited for calculation of signals with TCAD simulation programs.

One can add the entire discrete circuitry like biasing network, amplifier etc. to the TCAD model and directly find the voltages induced on the nodes.

In TCAD one can e.g. use a triangular current pulse with duration T and peak value $I_p$ and then use $Q_0 = I_p \times T/2$, where T must be chosen much smaller than the reaction time of the medium.

In general any current $I(t)$ with $Q_0 = \int I(t)\,dt$ can be used, as long as the duration is much smaller than the reaction time of the medium.
2.2. Induced charge on grounded electrode

This weighting field is defined by placing a step voltage on the electrode in question and calculating the resulting electric field.

This theorem is well suited for calculation of signals with TCAD simulation programs when the input impedance of the amplifier that connects to the electrode is negligible with respect to the other impedances in the circuit.

In that case $I_n(t) = -\frac{dQ_n(t)}{dt}$ directly gives the input current to the amplifier.
Induced Current on grounded electrodes

The induced current can also be calculated by a ‘weighting field’ or ‘weighting vector’ \( W_n \) that is caused by a small voltage pulse on the electrode in question.

\( W(x, t) \) has units of V/cm*s and therefore does not represent an electric field.

Using this weighting vector the induced current can be calculated directly.

This weighting vector will always have a ‘prompt’ component that follows the short pulse and a ‘delayed’ component that includes the reaction of the medium.

When using this weighting field for numerical simulations it is useful to use these two components separately to avoid numerical issues.
**Induced Currents and Voltages**

The charges $Q_{\text{ind}}^n(t)$ and current $I_{\text{ind}}^n(t) = -\frac{dQ_{\text{ind}}(t)}{dt}$ are related to the voltages $V_{\text{ind}}^n(t)$ induced on the electrodes that are connected by the discrete impedance elements $z_{mn}(s)$ through the admittance matrix $y_{mn}(s)$.

Let us assume we have calculated the weighting field $H(x, t)$ or the weighting vector $W(x, t)$ for the induced charge or the induced current, for the case where the other electrodes are held at fixed potentials i.e. the interconnecting impedance elements $z_{mn}(s)$ do not play a role.

We perform the Laplace transform and have $H_n(x, s)$ and $W_n(x, s)$.

We define the admittance matrix $y_{mn}(s)$ by integrating these weighting fields over the electrode surfaces.
The electrodes and the medium can be represented by nodes that are connected by impedance elements.

The induced voltage signals for the case where the electrodes are connected by arbitrary impedance elements can then be calculated by the induced currents on grounded electrodes together with the equivalent circuit diagram.

In case the medium has no conductivity, i.e. $\sigma=0$, these impedance elements are $Z_{nm}=1/sC_{nm}$ with $C_{nm}$ being the mutual electrode capacitances.

This second method for calculating the induced voltages has the advantage that one calculates the currents $I^\text{ind}_n(t)$ and the impedance elements $Z_{mn}(s)$ once and can then perform all further calculations for different readout and biasing circuits in a separate SPICE simulation.